

DOCKET NO: 278426US0PCT

IN THE UNITED STATES PATENT & TRADEMARK OFFICE

IN RE APPLICATION OF :
MITSUGU ABE, ET AL. : EXAMINER: ROSE, R.
SERIAL NO: 10/549,294 :
FILED: SEPTEMBER 16, 2005 : GROUP ART UNIT: 3723
FOR: MATERIAL FOR PURIFICATION :
OF SEMICONDUCTOR POLISHING
SLURRY, MODULE FOR PURIFICATION
OF SEMICONDUCTOR POLISHING
SLURRY AND PROCESS FOR
PRODUCING SEMICONDUCTOR
POLISHING SLURRY

AMENDMENT

COMMISSIONER FOR PATENTS
ALEXANDRIA, VIRGINIA 22313

SIR:

In response to the Final Rejection dated November 16, 2007, please amend the above-identified application as follows:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks/Arguments begin on page 9 of this paper.